

Title (en)

METHOD FOR THE PRODUCTION OF SYNTHETIC SILICA GLASS

Title (de)

VERFAHREN ZUR HERSTELLUNG VON SYNTHETISCHEM QUARZGLAS

Title (fr)

PROCEDE DE PRODUCTION DE VERRE DE QUARTZ SYNTHETIQUE

Publication

EP 1590303 A1 20051102 (DE)

Application

EP 04703768 A 20040121

Priority

- EP 2004000442 W 20040121
- DE 10302914 A 20030124

Abstract (en)

[origin: WO2004065314A1] The invention relates to a previously known method for producing synthetic silica glass, comprising the following steps: a gas stream containing a vaporizable initial substance, which can be converted into SiO₂ by means of oxidation or flame hydrolysis, is formed; the gas stream is delivered to a reaction zone in which the initial substance is converted so as to form amorphous SiO₂ particles; the amorphous SiO₂ particles are deposited on a support so as to form an SiO₂ layer; and the SiO₂ layer is vitrified during or following deposition of the SiO₂ particles in order to obtain the silica glass. The aim of the invention is to create an economical method for producing synthetic silica glass, which is characterized by a favorable damaging behavior towards short-wave UV radiation while being particularly suitable for producing an optical component used for transmitting high-energy ultraviolet radiation having a wavelength of 250 nm or less. Said aim is achieved by using a mixture of a monomeric silicon compound containing a singular Si atom and an oligomeric silicon compound containing several Si atoms as an initial substance, provided that the oligomeric silicon compound in the mixture contributes less than 70 percent to the total silicon content.

IPC 1-7

C03B 19/14

IPC 8 full level

C03B 19/14 (2006.01)

CPC (source: EP US)

C03B 19/1415 (2013.01 - EP US); **C03C 3/06** (2013.01 - EP US); **C03B 2207/30** (2013.01 - EP US); **C03B 2207/32** (2013.01 - EP US); **C03B 2207/34** (2013.01 - EP US)

Citation (search report)

See references of WO 2004065314A1

Designated contracting state (EPC)

AT DE FR GB NL

DOCDB simple family (publication)

WO 2004065314 A1 20040805; DE 10302914 A1 20040812; DE 10302914 B4 20051229; EP 1590303 A1 20051102; JP 2006516525 A 20060706; US 2006107693 A1 20060525

DOCDB simple family (application)

EP 2004000442 W 20040121; DE 10302914 A 20030124; EP 04703768 A 20040121; JP 2006500003 A 20040121; US 54309305 A 20050819